Proposal Transmittal Form Office of Sponsored Projects Seattle University

Addendum C Export Control Checklist

Project Title	SU Lead Principal Investigator/Director

To ensure compliance with federal export control laws and regulations, a PI must complete this questionnaire if the PI's proposed project will involve sending materials outside the U.S. or will involve collaborating with personnel who are nationals of a country other than the U.S. If the answer to any of the following questions is "yes," OSP will conduct a further export control review of the project, as appropriate.

Does this project or agreement:		NO
Restrict researcher participation (faculty, student, others) based on national origin or citizenship?		
Require researcher participation in US-citizen-only meetings?		
Grant the sponsor a right of prepublication review for matters other than the inclusion of patent and/or proprietary sponsor information?		
Provide that any part of the sponsoring, granting, or establishing documents may not be disclosed (including if a non-disclosure agreement applies)?		
Involve access to any controlled technical data or technology (hardware or software) furnished to Seattle University that is proprietary or confidential to a sponsor or third party?		
Involve materials such as agents, pathogens, or toxins, or other materials that must be obtained under a Materials Transfer Agreement?		
Involve research containing source code for encrypted software (other than publicly available software distributed at no charge)?		
Involve research, information or software that could be used in the development of weapons of mass destruction (nuclear, biological, chemical), or their delivery systems?		
Involve equipment, software, services or technology that is on the United States Munitions List ("USML") under the International Traffic in Arms Regulations?		
Involve equipment, software, services or technology that is on the Commerce Control List ("CCL") under the Export Administration Regulations?		
Involve technical information or instructions concerning equipment, software or technology on the USML or the CCL?		